

INFORMATION DISCLOSURE STATEMENT BY APPLICANT <i>(Use as many sheets as necessary)</i>		<i>Complete If Known</i>	
		Application Number	Unknown
		Filing Date	Even Date Herewith
		First Named Inventor	Kilian, Wayne
		Group Art Unit	Unknown
		Examiner Name	Unknown
Sheet 1 of 1		Attorney Docket No: H0006149 (256.206US1)	

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EXAMINER CRANE DATE CONSIDERED 9/04